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Murayama et al.

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(54) **EL DISPLAY AND PRODUCTION METHOD THEREOF**

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(75) Inventors: **Koji Murayama, Yasu-gun (JP); Takatoshi Tsujimura, Fujisawa-shi (JP)**

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Correspondence Address:
MILDE & HOFFBERG, LLP
10 BANK STREET
SUITE 460
WHITE PLAINS, NY 10606 (US)

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(57) **ABSTRACT**

(73) Assignees: **CHI MEI OPTOELECTRONICS CORP; KYOCERA CORPORATION**

An EL display (10a) of the invention includes a substrate (12), a wall (14) arranged on the substrate (12) to form a plurality of openings corresponding to pixel areas, a plurality of pixel patterns (16) formed in the openings and a first lubrication layer (18a) formed on the wall (14).

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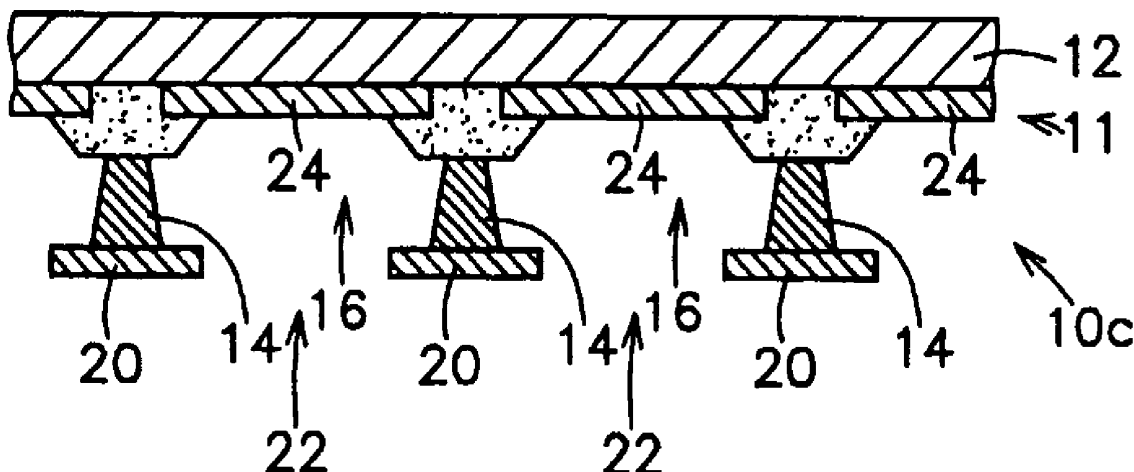


FIG. 1

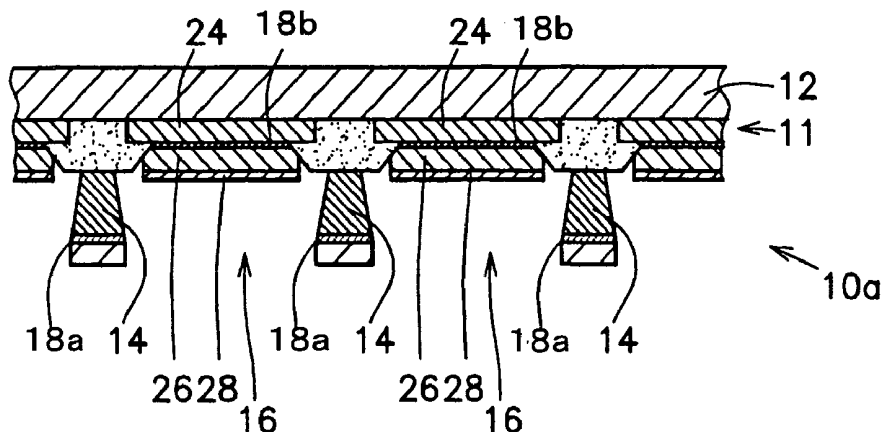


FIG. 2(a)

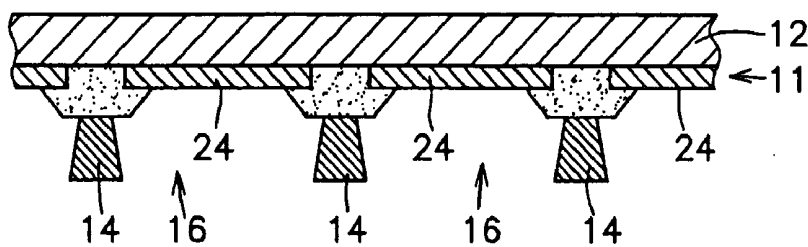


FIG. 2(b)

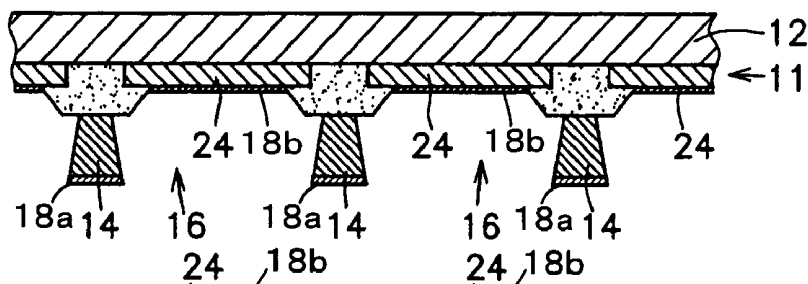


FIG. 2(c)

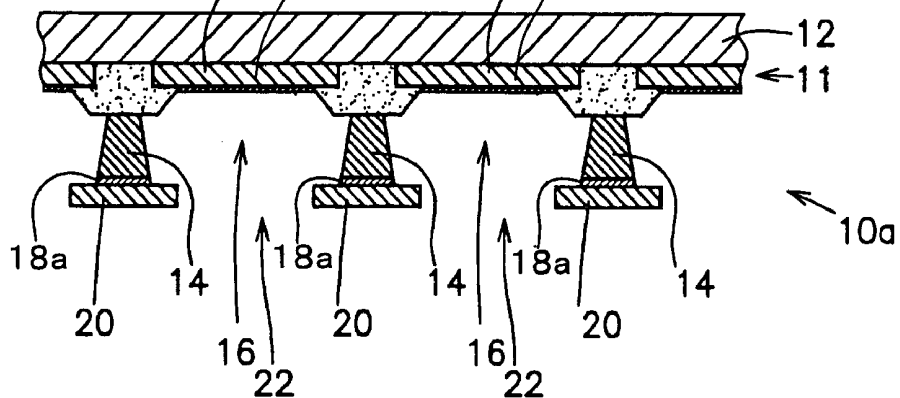


FIG. 3(a)

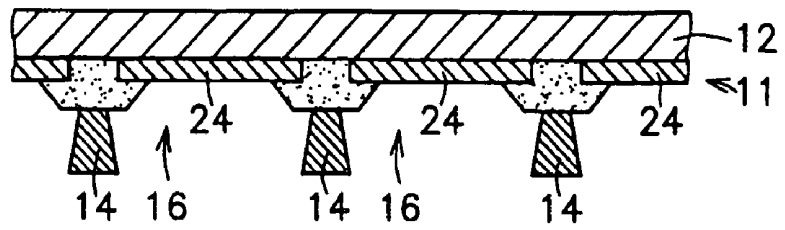


FIG. 3(b)

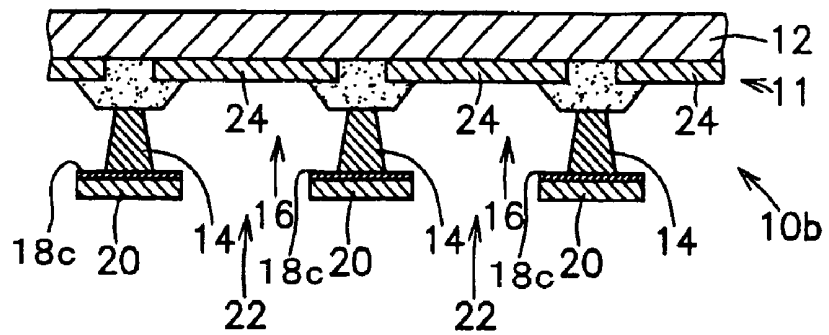
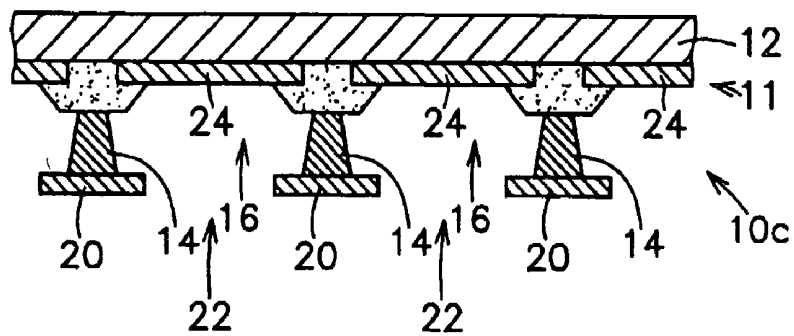


FIG. 4



EL DISPLAY AND PRODUCTION METHOD THEREOF

BACKGROUND OF THE INVENTION

[0001] 1. Field of the Invention

[0002] The present invention relates to an EL (Electroluminescence) display and a method of production thereof.

[0003] 2. Description of Related Art

[0004] In recent years, attention has been given to an OLED (Organic Light Emitting Device) ("All About Organic EL", by Junji Kido, published by Nippon Jitsugyo Publishing Co., Ltd., Feb. 20, 2003). The OLED is now used as a display of various products including mobile phones and digital cameras.

[0005] In applications of the well-known OLED to a full-color display, three main methods are available: (1) whole-surface white OLED and color filters, (2) whole-surface blue OLED and CCM (Color Changing Media), and (3) cells formed separately for R (Red), G (Green) and B (Blue). The RGB separate forming method, which has the highest emission efficiency and realizes a display high in color purity, has most advanced.

[0006] The RGB separate forming method includes a shadow mask method in which the cells are formed separately by evaporation using a metal mask (hereinafter, referred to as "mask") **20** shown in **FIG. 4** ("All About Organic EL", by Junji Kido, published by Nippon Jitsugyo Publishing Co., Ltd., Feb. 20, 2003). Before the cells are separately formed, alignment marks on the mask **20** and a substrate **11** are measured with a CCD (Charge Coupled Device) camera, the shift of the mask **20** from the relative position is calculated by a computer, and the mask **20** is moved in accordance with the result of calculation. This is an alignment process. Normally, one alignment operation cannot produce a sufficiently high accuracy, and therefore several alignment operations are conducted. Thus, the process of attaching the mask **20** and wall **14** closely to each other by a magnet and separating them from each other is repeated. As shown in **FIG. 4**, the mask **20** is set in position with respect to the substrate **11** in such a manner that all the pixel areas are open through holes **22** of the mask **20** at the time of evaporation.

[0007] In setting the mask **20** in position with respect to the substrate **11**, as described above, the mask **20** closely attached to the wall **14** are separated from the wall **14** in some cases. In this process, the mask **20** and the ribs **14** on the substrate **11** interfere with each other in some cases, and the mask **20** is caught by the wall **14** of the substrate **11**, so that the wall **14** of the substrate **11** are scratched or the mask **20** itself is damaged in some cases. This is because the wall **14** in contact with the mask **20** are made of polymer; therefore, the contact angle of the polymer with water is so small as at several degrees to several tens of degrees and the wettability thereof is high. As another reason, in the case where the ribs are formed of polymer not small in contact angle with water, the wettability of the wall is probably improved by oxygen plasma treatment or UV ozone treatment performed to clean an anode surface. Herein, the polymer making up the ribs is a photosensitive negative resist.

[0008] Once the wall are scratched as described above, the display performance of the EL display is probably reduced. Also, the mask, if damaged, is required to be replaced, which consumes time and reduces the productivity while at the same time increasing the production cost of the EL display.

[0009] This invention has been achieved in view of the problems described above, and an object thereof is to prevent the wall from being scratched by the mask deposited by evaporation and also to prevent the mask from being damaged.

SUMMARY OF THE INVENTION

[0010] According to one aspect of the invention, there is provided an EL display comprising a substrate, a wall arranged on the substrate to form a plurality of openings, a plurality of pixel patterns formed in the openings, and a first lubrication layer formed on the wall.

[0011] According to another aspect of the invention, there is provided a method of producing an EL display, comprising the steps of preparing a display substrate having a substrate, a wall arranged on the substrate to form a plurality of openings and a first lubrication layer formed on the wall, arranging a mask having a plurality of holes corresponding to the openings in contact with the first lubrication layer on the display substrate, and evaporating an evaporation source arranged outside the mask while depositing the evaporated substance from the evaporation source on the display substrate in the openings through the holes of the mask.

[0012] According to still another aspect of the invention, there is provided a method of producing an EL display, comprising the steps of preparing a display substrate having a substrate, and a wall arranged on the substrate to form a plurality of openings, preparing a mask having a third lubrication layer on at least a main surface of a tabular member having a plurality of holes corresponding to the openings, arranging the mask on the display substrate in such a manner that the third lubrication layer is in contact with the wall, and evaporating an evaporation source arranged outside the mask while depositing the evaporated substance from the evaporation source in the openings through the holes of the mask.

BRIEF DESCRIPTION OF THE DRAWINGS

[0013] **FIG. 1** is a sectional view showing an EL display according to an embodiment of the invention;

[0014] **FIGS. 2(a) to 2(c)** show a method of producing an EL display according to the invention, in which **FIG. 2(a)** is a diagram for explaining a step of preparing a display substrate, **FIG. 2(b)** is a diagram for explaining a step of forming a first lubrication layer and a second lubrication layer, and **FIG. 2(c)** is a diagram for explaining alignment;

[0015] **FIGS. 3(a) and 3(b)** show another method of producing an EL display according to the invention, in which **FIG. 3(a)** is a diagram for explaining a step of preparing a display substrate, and **FIG. 3(b)** is a diagram for explaining a step of alignment using a mask having a third lubrication layer; and

[0016] **FIG. 4** is a diagram for explaining a conventional method of producing an EL display in which a display substrate and a mask are aligned with each other.

DESCRIPTION OF THE PREFERRED EMBODIMENTS

[0017] Embodiments of the invention is explained below with reference to the drawings. An EL display used for the explanation is an organic EL display.

[0018] An EL display **10a** according to the invention including a display substrate **11** shown in **FIG. 1** comprises a substrate **12**, a wall **14** arranged on the substrate **12** to form a plurality of openings, a plurality of pixel patterns **16** formed in the openings, and a first lubrication layer **18a** formed on the wall **14**.

[0019] The substrate **12** is transparent for the EL display of bottom emission type, and reflects light for the EL display of top emission type.

[0020] The wall **14** is each formed to surround a pixel on two or four sides. The wall **14** is formed of such a material as a photosensitive negative resist. This resist has a very small contact angle of several to several tens of degrees with water. Nevertheless, a resist having a contact angle of 50 to 60 degrees with water is also used with comparative frequency. The wall **14** is connected to a plurality of walls on the display substrate **11**.

[0021] The first lubrication layer **18a** has preferably a smaller friction coefficient than the wall **14**. The contact angle of the material making up the lubrication layer **18** with water is preferably set at 80° to 120°. The contact angle is so large that a mask **20**, if used for production of the display **10a**, is hardly caught at the time of evaporation. Thus, the wall **14** are not easily damaged.

[0022] The first lubrication layer **18a** is formed of such a material as fluororesin, silicone resin or polyvinyl chloride. The fluororesin, if employed, is preferably composed of $CF_x(1.3 \leq x \leq 2)$ or $CH_xF_y(0 < x \leq 1, 1 \leq y \leq 2, 1.3 \leq x+y \leq 2)$. The CF_x or CH_xF_y film has the properties similar to polytetrafluoroethylene.

[0023] Each pixel pattern **16** includes at least an organic layer **26**, an anode **24** and a cathode **28** sandwiching the organic layer **26**, and a wiring pattern and a switching element for supplying a current to the anode **24**.

[0024] The organic layer **26** includes a light emitting layer formed of an organic material such as Alq_3 , anthracene, Znq_2 , $Balq_2$, $Almq_3$, $Tb(acac)_3$, DCJTb, C545T, perylene, quinaclidone derivative, rubren or rhodamine, which emits light at a predetermined wavelength upon electrical conduction thereof. This organic layer **26** emits light for display at a predetermined brightness by the energy released at the time of recombination of holes and electrons in the light emitting layer.

[0025] In the EL display **10a** according to the invention, the first lubrication layer **18a** is arranged on the wall **14**, and therefore not easily scratched at the time of production. Thus, a satisfactory display is realized.

[0026] Next, a method of producing the EL display **10a** is explained.

[0027] (1) First, as shown in **FIG. 2(a)**, a display substrate **11** having a substrate **12** and a wall **14** arranged on the substrate **12** to form a plurality of openings corresponding to pixel areas is prepared.

[0028] Anodes **24** made of ITO, for example, are formed in such a manner that ITO of a predetermined thickness is formed by a well-known thin film forming technique, or specifically, by evaporation or sputtering, and the film thus formed is processed to a predetermined pattern by using the technique of photolithography or etching. The wall **14** is formed in such a manner that a photosensitive photoresist (such as novolac resin or epoxy resin) is coated in a predetermined thickness on the substrate by the spin coat method or the like and, also, is sensitized into a predetermined pattern, and the unnecessary portions are removed by chemical etching.

[0029] (2) Next, as shown in **FIG. 2(b)**, a first lubrication layer **18a** and a second lubrication layer **18b** is formed on the wall **14** and the anodes **24**, respectively. The first lubrication layer **18a** and the second lubrication layer **18b** made of fluororesin, for example, is formed in such a manner that a high vacuum plasma (pressure of 0.05 to 0.3 Pa) is generated in a fluorocarbon gas atmosphere thereby to deposit the gas in the atmosphere on the wall **14** and the anodes **24**. In the process, the surface of each anode **24** is cleaned while the work function thereof increases. Also, the second lubrication layer **18b** formed on the anodes **24** has a lower hole injection (movement) barrier with respect to the organic layer due to the improved work function on the surface of the anodes **24**, and therefore holes can be more easily injected into the organic layer formed later.

[0030] (3) Then, as shown in **FIG. 2(c)**, a mask **20** having holes **22** corresponding to the openings is prepared. The mask **20** is brought into contact with the first lubrication layer **18a** on the wall **14** and arranged on the display substrate **11**.

[0031] The mask **20** and the wall **14** are brought into contact with each other in such a manner that a magnet is arranged on the surface of the display substrate **11** opposite to the ribs **14**, and the mask **20** is attached closely to the lubrication layer **18** on the ribs **14** by the magnetic force of the magnet. Incidentally, in the case where the mask **20** is fixed in position by the magnetic force of the magnet in this way, the mask **20** is formed of a magnetic material such as a Ni alloy, a Ni—Co alloy, a Fe—Ni—Co alloy or the like.

[0032] The display substrate **11** and the mask **20** are aligned with each other in such a manner that the alignment marks formed on the display substrate **11** and the mask **20** are imaged by a CCD camera and the shift between the display substrate **11** and the mask **20** is calculated from the relative distance thereof, and the mask **20** is moved by the calculated distance. Normally, a single alignment process fails to produce a sufficiently high accuracy and the alignment process is repeated several times. At the same time, the first lubrication layer **18a** can successfully prevent the wall **14** and the mask **20** from being caught by each other, so that the display substrate **11** is not scratched or the mask **20** is not damaged.

[0033] (4) The evaporation is carried out using the mask **20**. Specifically, the evaporation source arranged above the mask **20** on the display substrate **11** is evaporated. The evaporated substance is deposited on the display substrate **11** in the openings through the holes **22** of the mask **20** thereby to form the pixel patterns **16**. The evaporated substance is an organic material making up the organic layer and a metal material (such as Ca, Mg, LiF/Al, AlLi, etc.) making up the

cathode. At the same time, a protective film of an inorganic material such as SiN or SiO may be formed to protect the cathode.

[0034] As described above, according to the invention, the provision of the first lubrication layer 18a prevents the display substrate 11 from being scratched or the mask 20 from being damaged at the time of alignment of the mask 20. Thus, the performance reduction of the EL display 10a is suppressed.

[0035] The configuration in which the EL display 10a includes the first lubrication layer 18a is described above. The lubrication layer, however, may be formed on the mask instead of on the EL display with equal effect. The method of production with such a configuration is explained below.

[0036] (1) As shown in FIG. 3(a), a display substrate 11 including a substrate 12 and a wall 14 forming a plurality of openings corresponding to pixel areas arranged on the substrate 12 is prepared. Except for the lack of the first lubrication layer 18a on the display substrate 11, the method of producing the display substrate 11 is the same as the one described above and therefore is not described.

[0037] (2) As shown in FIG. 3(b), a mask 20 having holes 22 corresponding to the openings and a third lubrication layer 18c formed on at least a main surface of the mask 20 is prepared. This mask 20 is arranged on the display substrate 11 in such a manner that the third lubrication layer 18c is in contact with the wall 14.

[0038] The third lubrication layer 18c on the mask 20 is formed in the same way as it is formed on the wall 14 or the anode 24. The mask 20 and the display substrate 11 are brought into contact with each other by arranging a magnet on the surface of the display substrate 11 opposite to the wall 14 and attaching the mask 20 closely to the wall 14 by the magnetic force of the magnet.

[0039] The mask 20 and the display substrate 11 are aligned with each other in the same way as described above although the mask 20 includes the third lubrication layer 18c. The configuration of the third lubrication layer 18c on the mask 20 is similar to that of the first lubrication layer 18a formed on the wall 14. Since the third lubrication layer 18c is formed on the mask 20, as in the way described above, the mask 20 and the wall 14 are hardly caught by each other. Thus, it is possible to prevent the display substrate 11 from being scratched or the mask 20 from being damaged.

[0040] (3) An evaporation source arranged outside the mask 20 is evaporated, and the evaporated substance is deposited in the openings through the holes 22 of the mask 20 thereby to form a plurality of pixel patterns 16. Each pixel pattern 16 includes an organic layer and a cathode. Once the organic layer emits light, the display is made possible.

[0041] According to this embodiment, the provision of the third lubrication layer 18c on the mask 20 makes it difficult for the mask 20 and the wall 14 to be caught by each other and therefore the display substrate 11 is successfully prevented from being scratched. As a result, the EL display 10b can be maintained at a high display performance. Also, the damage to the mask 20 is suppressed, so that the mask 20 is required to be changed less frequently for an improved productivity and a lower production cost.

[0042] Unlike in the aforementioned embodiments in which the first lubrication layer 18a or the third lubrication layer 18c is formed on the display substrate 11 or the mask 20, the first lubrication layer 18a and the third lubrication layer 18c may alternatively be formed on the display substrate 11 and the mask 20, respectively.

[0043] The organic EL display with reference to which the embodiments are described above may be replaced with an inorganic EL display in which an inorganic layer emits light. The wall 14 may be separated.

[0044] Also, as long as the alignment is made using the mask 20, the production process is not limited to the vapor deposition. Further, a positive resist, instead of the negative resist used in the above-mentioned embodiments, may be used to form the wall.

[0045] According to this invention, the mask and the display substrate are caught by each other less frequently. As a result, the ribs are successfully prevented from being scratched and, also, the mask itself is prevented from being damaged.

[0046] This invention can be embodied in the form variously improved, corrected or modified based on the knowledge of those skilled in the art without departing from the spirit and scope of the invention.

[0047] The present application claims priority from Japanese Patent Application No. 2004-182107, the content of which is hereby incorporated by reference.

1. An EL display with a plurality of pixels arranged, comprising:

a substrate;

a wall arranged on the substrate to form a plurality of openings;

a plurality of pixel patterns formed in the openings; and

a first lubrication layer formed on the wall.

2. An EL display according to claim 1,

wherein the first lubrication layer has a smaller friction coefficient than the wall.

3. An EL display according to claim 1,

wherein the first lubrication layer is composed of a material having a contact angle of 80° to 120° with respect to water.

4. An EL display according to claim 1,

wherein the first lubrication layer is formed of fluoro-resin, silicone resin or polyvinyl chloride.

5. An EL display according to claim 1,

wherein the pixel pattern includes an organic light emitting layer.

6. An EL display according to claim 1,

wherein the first lubrication layer is formed of $CF_x(1.3x2)$ or $CH_xF_y(0 < x < 1, 1 < y < 2, 1.3 < x + y < 2)$.

7. An EL display according to claim 1,

wherein the pixel pattern comprises a first electrode, a second lubrication layer on the first electrode, an organic layer on the second lubrication layer and a

second electrode on the organic layer, the second lubrication layer and the first lubrication layer being formed of same material.

8. A method of producing an EL display, comprising the steps of:

preparing a display substrate including a substrate, a wall arranged on the substrate to form a plurality of openings and a first lubrication layer formed on the wall;

preparing a mask with a plurality of holes corresponding to the openings;

arranging the mask on the display substrate into contact with the first lubrication layer; and

evaporating an evaporation source arranged outside the mask; and

depositing a evaporated substance from the evaporation source on the display substrate in the openings through the holes of the mask thereby to form a plurality of pixel patterns.

9. A method of producing an EL display according to claim 8,

wherein the first lubrication layer has a smaller friction coefficient than the wall.

10. A method of producing an EL display according to claim 8,

wherein the first lubrication layer is composed of a material having a contact angle of 80° to 120° with respect to water.

11. A method of producing an EL display according to claim 8,

wherein the first lubrication layer is formed of fluororesin, silicone resin or polyvinyl chloride.

12. A method of producing an EL display according to claim 8,

wherein the mask is formed of a metal material, and the mask arranged on the display substrate and the display substrate are kept in contact with each other by magnetic attraction force.

13. A method of producing an EL display according to claim 8,

wherein the pixel pattern comprises a first electrode, a second lubrication layer on the first electrode, an

organic layer on the second lubrication layer, and a second electrode on the organic layer, the first lubrication layer and the second lubrication layer being formed in a same process.

14. A method of producing an EL display, comprising the steps of:

preparing a display substrate including a substrate and a wall arranged on the substrate to form a plurality of openings;

preparing a mask with a third lubrication layer formed on at least a main surface of a tabular member having holes corresponding to the openings;

arranging the mask on the display substrate in such a manner that the third lubrication layer comes into contact on the wall,

evaporating an evaporation source arranged outside the mask; and

depositing evaporated substance from the evaporation source in the openings through the holes of the mask thereby to form a plurality of pixel patterns.

15. A method of producing an EL display according to claim 14,

wherein the third lubrication layer has a smaller friction coefficient than the tabular member.

16. A method of producing an EL display according to claim 14,

wherein the third lubrication layer is composed of a material having a contact angle of 80° to 120° with respect to water.

17. A method of producing an EL display according to claim 14,

wherein the third lubrication layer is formed of fluororesin, silicone resin or polyvinyl chloride.

18. A method of producing an EL display according to claim 14,

wherein the mask is formed of a metal material, and the mask arranged on the display substrate and the display substrate are kept in contact with each other by magnetic attraction force.

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专利名称(译)	EL显示器及其制造方法		
公开(公告)号	US20050280356A1	公开(公告)日	2005-12-22
申请号	US11/154409	申请日	2005-06-16
[标]申请(专利权)人(译)	群创光电股份有限公司 京瓷株式会社		
申请(专利权)人(译)	奇美电子股份有限公司 京瓷株式会社		
当前申请(专利权)人(译)	群创光电		
[标]发明人	MURAYAMA KOJI TSUJIMURA TAKATOSHI		
发明人	MURAYAMA, KOJI TSUJIMURA, TAKATOSHI		
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优先权	2004182107 2004-06-21 JP		
其他公开文献	US7432650		
外部链接	Espacenet USPTO		

摘要(译)

本发明的EL显示器 (10a) 包括基板 (12) , 设置在基板 (12) 上以形成对应于像素区域的多个开口的壁 (14) , 形成在基板 (12) 中的多个像素图案 (16) 。 开口和形成在壁 (14) 上的第一润滑层 (18a) 。

